Effect of Synthesis Temperature on the Composition of Electrolytic Iron Phosphide

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ABSTRACT
In this study, we investigated the composition of an electrolytic Fe phosphide at different synthesis temperatures. We found that the ratio of Fe in the electrodeposit increases with synthesis temperature, whereas the oxygen content introduced into the electrodeposit by the atmospheric oxidation of Fe decreases. The aim of this study was to identify the reason for this effect. For this purpose, the ratio of Fe and P in the electrodeposits prepared at different temperatures was analyzed in depth. In addition, the types and ratios of Fe phosphide phases were considered. It was proved that with increase in temperature, a significant amount of Fe reacted with P to form Fe phosphide phases, and consequently, the amount of residual pure Fe that would react directly with oxygen decreased.

Keywords: Fe phosphide, Electrodeposition, Temperature, Composition

1. Introduction
Metal phosphides are functional materials used in a broad range of applications, including high-energy-density supercapacitors and lithium battery electrodes [1-3], low-cost, high-efficiency catalysts [4], high-efficiency solar cell electrodes [5], radiation detectors [6], and wear-resistant thin films [7]. Metal phosphides are fabricated by a variety of methods. For instance, they are produced in the powder form by ball milling [8] and solid- and liquid-phase syntheses [9, 10], and in the thin-film form by chemical vapor deposition [11] and phosphorization [12]. These methods, however, present different challenges. Ball milling is problematic because it requires a long time for completion of the synthesis and causes particle cohesion. Solid-phase synthesis is not useful for producing large quantities of high-purity compounds. In contrast, liquid-phase synthesis has the advantage of producing high-purity powder; however, it is expensive and involves various time-consuming complex processes. Besides, the chemical vapor deposition method, which is used to produce thin films, requires expensive equipment and elaborate infrastructure, and it is not useful for large-area synthesis. Consequently, finding an efficient and reliable method to produce metal phosphides remains a key research topic.

Electrolytic plating is an economical method for thin film synthesis, which can be performed using relatively simple equipment such as electrochemical cells and a current/voltage source. Moreover, the amount of electrodeposit formed on the substrate and its composition, purity, and structure can be easily controlled by adjusting the applied current or voltage, temperature, or electrolyte composition [13], which allows for large-area synthesis. However, using electrolytic plating to synthesize a specific metal phosphide remains a challenging task mainly because of the complicated deposition mechanism. There has been limited research regarding the changes in the characteristics of metal phosphate electrodeposits depending on the electrolytic plating conditions (e.g., electrolyte pH [14]). The present study examined the composition of an electrolytic Fe phosphide at differ-
ent synthesis temperatures. The elemental composition of the electrodeposits is first presented, and the abnormal change in oxygen content with respect to iron is put forth as a question. To understand such compositional variation, the Fe-only phase and phosphide phase were quantitatively analyzed separately.

2. Experimental

The plating solution contained 0.72 M FeSO$_4$·7H$_2$O (Junsei Chemical Co. Ltd., Japan), 0.36 M NaH$_2$PO$_2$·H$_2$O (Junsei Chemical Co. Ltd., Japan), 0.11 M H$_2$NCH$_2$COOH (Junsei Chemical Co. Ltd., Japan), and 5 mM H$_2$C$_2$O$_4$ (Sigma-Aldrich, U.S.). H$_2$SO$_4$ (Duksan Pure Chemicals Co. Ltd., Korea) was added to the solution to maintain the pH at 2.3. A high-purity copper foil (99.8%) (Alfa Aesar, U.K.), pretreated with dilute H$_2$SO$_4$ and washed with distilled water (to remove the native oxide layer), was used as the substrate. The exposed area was 0.25 cm$^2$. A three-electrode electrochemical cell was constructed using a platinum wire and a saturated calomel electrode (SCE), which were used as the counter and reference electrodes, respectively. To synthesize the Fe phosphide thin film, a constant voltage of -1.7 V vs. SCE was applied for 10 s within the temperature range of 10-70°C using an IviumStat instrument (Ivium Technologies B.V., The Netherlands). The electrolyte was stirred to eliminate the evolved hydrogen gas, which would otherwise be adsorbed on the surface of the electrodes during synthesis.

Fig. 1 presents the surface morphology of the electrolytic Fe phosphide thin films synthesized at different temperatures. All the samples showed a uniform morphology, making it difficult to distinguish between them. The cracks on the surface neither changed with temperature, nor appeared in repeated experiments, implying that crack formation occurred during the handling process after plating. At all the studied temperatures, the samples were characterized as amorphous materials without long-range ordering, as shown in Fig. 2.

![Image](https://via.placeholder.com/150)

Fig. 3 shows the results of the surface composition analysis of the samples electroplated at 10-70°C. The compositions indicated in the figure represent the average values from three spots randomly selected on the electrodeposits. Iron, phosphorus, copper (used as the substrate), and oxygen were detected. Electrolytic Fe phosphide is known to form through the following mechanism [14]:

\[
\begin{align*}
\text{H}_2\text{PO}_2^- + 5\text{H}^+ + 4e^- & \rightarrow \text{PH}_3 + 2\text{H}_2\text{O} \\
2\text{PH}_3 + 3\text{Fe}^{2+} & \rightarrow 3\text{Fe} + 2\text{P} + 6\text{H}^+ \\
\text{Fe}^{2+} + 2e^- & \rightarrow \text{Fe}
\end{align*}
\]

Fe and P, the major components of the electrodeposits, are plated at a uniform ratio of 3:2 (Eqs. (1) and (2)), and additional plating involving only the Fe phase takes place simultaneously (Eq. (3)). Considering the deposition mechanism, it is noted in Fig. 3 that with increase in temperature, the Fe content increases, whereas the P content decreases. These results indicate that the increase in plating rate due to temperature is greater for Fe plating (Eq. (3)) than for Fe-P mixed plating (Eqs. (1) and (2)), i.e., the activation energy, which is a measure of the temperature sensitivity of the reaction, might be higher in the former case. On the other hand, a significant amount of Cu, which is used as the substrate, is found only at low temperatures (10°C). This might be because the electrodeposited is very thin at low temperatures, at which plating is relatively slow. For instance, the thickness of the 10°C-sample (<300 nm) is much smaller than that of the 25°C-sample (>400 nm) and 70°C-sample (>700 nm), as presented in the insets in Fig. 1.

The presence of oxygen in the deposits is particularly noteworthy in Fig. 3 because oxygen is not involved in any part of the deposition reactions shown in Eqs. (1)-(3). To the best of our knowledge, there are no reports on the oxidation of Fe phosphide and the incomplete reduction of hypophosphite in the...
electrolyte for incorporation into the electrodeposits. Instead, considering that Fe has a far greater tendency to be oxidized as compared with P [15,16], the presence of oxygen in the deposits may be attributed to atmospheric oxidation of Fe. Oxygen has frequently been detected in electroplated metals due to atmospheric oxidation [17]. Considering the mechanism by which oxygen is introduced into the deposit, the amount of oxygen must critically depend on the amount of Fe. More precisely, the amount of oxygen increases proportionately with the amount of Fe available to react with it. Unexpectedly, composition analysis (Fig. 3) shows an increase in the Fe ratio and a decrease in the oxygen ratio in the electrodeposit as the synthesis temperature is raised. This indicates that the Fe content in the deposit increases, while the actual amount of Fe available for reaction with oxygen decreases. The above arguments strongly suggest that with increase in synthesis temperature, the
amount of Fe plated according to Eq. (3) increases; however, a greater percentage of the plated Fe is involved in the formation of Fe phosphide. Consequently, the amount of pure Fe available for reaction with oxygen decreases.

To experimentally verify this claim, the concentrations and phases of two samples prepared at different temperatures (25 and 50°C) were thoroughly analyzed. Fig. 4(a) presents the compositional depth profile of the electrodeposit synthesized at 25°C. Except for the early stage of plating (to a depth of ca. ≥300 nm), an even distribution of Fe and P could be seen regardless of the thickness, which is consistent with the results reported in literature [14]. Besides, the average Fe/P ratio was about 78:22. Fig. 4(b) shows the O 1s X-ray photoelectron spectra used to analyze the binding form of oxygen. Based on deconvolution of the peaks, it was determined that oxygen is present as \( \text{Fe}_2\text{O}_3 \) (530.2 eV [18]) and \( \text{FeOOH} \) (531.5 eV [19]). Fig. 4(c) shows the Fe 2p X-ray photoelectron spectra used to determine the form of Fe in the deposit. It was confirmed that Fe is present as \( \text{Fe}_2\text{P} \) (706.6 eV [20]), \( \text{FeP} \) (707.2 eV [21]), \( \text{FeOOH} \)
(709.0 eV [22] and 719.9 eV [23]), Fe (707.7 eV [24] and 720.6 eV [25]), and Fe$_2$O$_3$ (711.0 eV [23] and 722.6 eV [26]). In order to improve the reliability of the XPS analyses, all the binding energies of Fe oxides and Fe phosphides in the literature were considered when deconvoluting the spectra. The ratio of the corresponding peak areas (the ratio of each phase) was approximately 1.28:44:11:16. Based on this, the Fe:P ratio was calculated to be 80:20, which agreed well with the average Fe:P ratio (78:22) estimated from Fig. 4(a).

Fig. 5(a) shows the compositional depth profile of the sample prepared at 50°C. There is a distinct increase in the Fe ratio as compared to that in the 25°C-sample. Fe and P are relatively evenly distributed (average Fe:P ratio of approximately 88:12) with the only exception at a depth of ≥300 nm, similar to the case of the 25°C-sample. Fig. 5(b) confirms that oxygen is bonded to Fe in the form of Fe$_2$O$_3$ (530.2 eV [18]) and FeOOH (531.5 eV [19]). Moreover, as shown in Fig. 5(c), Fe is present in the form of FeP (706.6 eV [20]), FeP (707.2 eV [21]), FeOOH (709.0 eV [22] and 719.9 eV [23]), Fe (707.7 eV [24] and 720.6 eV [25]), and Fe$_2$O$_3$ (711.0 eV [23], 722.6 eV [26]). The ratio of each peak area is 20:1:38:30:11. Accordingly, the Fe:P ratio was calculated to be 86:14, consistent with the average Fe:P ratio of 88:12 (Fig. 5(a)). On the other hand, no evidence was found in the XPS spectra regarding the presence of incomplete reduction products of hypophosphite (e.g., H$_3$PO$_3$). This strongly indicates that oxygen in the film mainly originates from the atmospheric oxidation of Fe after the electrolytic deposition.

In summary, the electrodeposition synthesized at higher temperatures showed a higher percentage of Fe (78% at 25°C and 88% at 50°C), most of which was present in the form of Fe phosphides. More precisely, Fe present as Fe phosphides (mainly FeP) in the 25°C-sample was about 30%, whereas Fe present as Fe phosphides (mainly FeP) in the 50°C-sample was approximately 41%. Accordingly, the amount of Fe available for reaction with oxygen, i.e., the Fe-only phase, decreased with increasing synthesis temperature.

4. Conclusions

In this work, it was demonstrated that the proportion of the phases (Fe-only and Fe phosphides) in an electrolytic Fe phosphide thin film significantly depends on the synthesis temperature. Because the Fe and Fe phosphide contents and the type of Fe-phosphide phase in the film directly affect its functionality, close attention should be paid to the synthesis temperature in order to obtain a particular thin film composition, and thus, the desired functionality. Electrolytic Fe phosphides with different Fe:P ratios prepared at various temperatures are being tested as electrode materials for functional electrochemical devices, and the results will be reported in a separate paper.

Acknowledgement

This research was supported by the National Research Foundation of Korea Grants funded by the Korea Government (NRF-2017R1D1A3B04031667). One of the authors (H. Kim) was supported by scholarship for graduate students in science and engineering funded by the Hyundai Motor Chung-Mong-Koo Foundation (CMKF-S-012).

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